



(11) **EP 1 047 127 B8**

(12) **CORRECTED EUROPEAN PATENT SPECIFICATION**

Note: Bibliography reflects the latest situation

(15) Correction information:

Corrected version no 1 (W1 B1)
INID code(s) 73

(51) Int Cl.:

H01L 21/8234 (2006.01)

(48) Corrigendum issued on:

28.02.2007 Bulletin 2007/09

(45) Date of publication and mention
of the grant of the patent:

29.11.2006 Bulletin 2006/48

(21) Application number: **00303273.7**

(22) Date of filing: **18.04.2000**

(54) **A method of forming a multi-layered dual-polysilicon structure**

Verfahren zur Herstellung einer vielschichtigen Doppel-Polysiliziumstruktur

Procédé pour fabriquer une structure multicouches double en polysilicium

(84) Designated Contracting States:
DE FR GB

(30) Priority: **22.04.1999 US 298068**

(43) Date of publication of application:
25.10.2000 Bulletin 2000/43

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